

## [ Broad Band Monitoring ]

The precise production of coating systems with complicated designs has developed to one of the major challenges in modern optical thin film technology.

Besides extended investigations in the stability and reproducibility of deposition techniques, a variety of approaches to control the growing layers has been studied on the way towards the targeted ideal process concept which would allow the realization of even extremely complicated coating designs in a linear chain without iteration steps.

Even though this ultimate production technique could not be achieved completely until now, the related research work of the last two decades furnished enormous progresses, especially in the field of online-monitoring in deposition processes.

The present workshop is dedicated to a comprehensive overview on the latest achievements in the area of thin film monitoring.

## [ How to get there ]

**Laser Zentrum Hannover e.V. (LZH),  
Hollerithallee 8, 30419 Hannover**



## [ Organizer ]

PhotonicNet GmbH

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## [ in cooperation with ]

Laser Zentrum Hannover e.V.

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# Photonic-Net

Innovationsnetz Optische Technologien

IN COOPERATION WITH

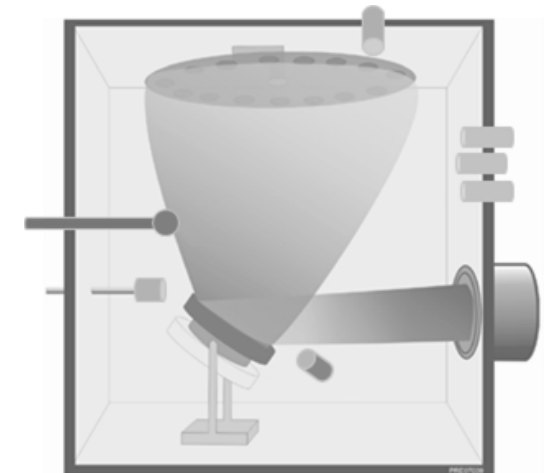


Research Center  
for Surface Technology



## Monitoring in Thin Film Production

[ Hanover, Germany  
February 20th, 2018 ]



### [ Agenda ]

<b>Welcome</b>	<b>09.30</b>
Detlev Ristau Laser Zentrum Hannover e.V., Hanover, Germany	
<b>Session I: Fundamentals</b>	
<b>Monitoring and Control of Optical Deposition Processes</b>	<b>09.40</b>
Henrik Ehlers Laser Zentrum Hannover e.V., Hanover, Germany	
<b>Design and Optical Monitoring</b>	<b>10.10</b>
Alexander Tikhonravov Lomonossov University, Moscow, Russia	
<b>Optical Monitoring in Modern Deposition Processes</b>	<b>10.40</b>
Detlef Arhilger Bühler Group, Leybold Optics, Alzenau, Germany	
<b>Coffee break, photograph</b>	<b>11.10</b>
<b>Session II: Applications</b>	
<b>Filter Systems</b>	<b>11.30</b>
Marc Lappschies Optic Balzers Jena GmbH, Jena, Germany	
<b>N.N.</b>	<b>12.00</b>
Dirk Isfort, Carl Zeiss GmbH, Oberkochen, Germany	
<b>Optical Monitoring in IBS</b>	<b>12.30</b>
Kai Starke CEC Cutting Edge Coatings GmbH, Hanover, Germany	

<b>Lunch break</b>	<b>12.40</b>
<b>Session III: Applications</b>	
<b>Chirped Mirrors</b>	<b>14.00</b>
Vladimir Pervak Ludwig-Maximilians-University, Munich, Germany	
<b>Prospects for the enhancement of PIAD processes by monitoring of optical thickness and plasma parameters</b>	<b>14.30</b>
Jens Harhausen Leibniz-Institute for Plasma Science and Technology, INP Greifswald, Germany	
<b>Coffee break</b>	<b>15.00</b>
<b>Session IV: Advanced Monitoring Concepts</b>	
<b>Optical Monitoring: New Approaches</b>	<b>15.30</b>
Sebastian Schlichting Laser Zentrum Hannover e.V., Hanover, Germany	
<b>Automatic generation of monochromatic monitoring spreadsheets</b>	<b>16.00</b>
Tatiana Amotchkina, Ludwig-Maximilians-University, Munich, Germany	
<b>Final remarks</b>	<b>16.30</b>
<b>Lab Tour LZH e.V.</b>	<b>16.40</b>
<b>End</b>	<b>18.00</b>

### [ Registration ]

**Binding Registration**  
Please register until **February 09th, 2018** the latest

**Fax: +49 511 / 277-1650**

or **ONLINE**

**E-Mail: [veranstaltung@photonicnet.de](mailto:veranstaltung@photonicnet.de)**

I will attend the workshop

Name

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Company / Institution

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Address

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Postal Code, City

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Phone No.

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E-Mail

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Member of competence network OT

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Date / Signature

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**Venue:**  
Laser Zentrum Hannover e.V.  
Hollerithallee 8  
30419 Hannover  
Germany

**PARTICIPATION FEE** (plus VAT 19%):

290,00 € per person  
230,00 € per person for Members of competence network OT